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PATENT APPLICATION

IN THE UNITED STATES PATENT AND TRADEMARK OFFICE

In re the Application of

Attn: OIPE

Noriyoshi SATO et al.

Group Art Unit: 2812

Application No.: 10/539,569

Docket No.: 124305

Filed: August 18, 2005

For: PLASMA GENERATOR, OZONE GENERATOR, SUBSTRATE PROCESSING
APPARATUS AND METHOD OF MANUFACTURING SEMICONDUCTOR
DEVICE

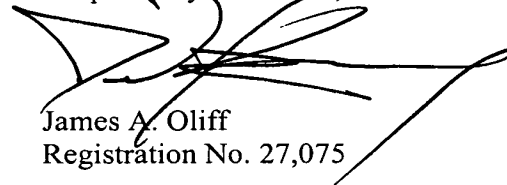
REQUEST FOR CORRECTION OF PALM RECORDS

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Sir:

Attached is a photocopy of the original filing receipt on which errors have been corrected in red. These errors are being brought to the attention of the Patent and Trademark Office so that it may correct its records.

Respectfully submitted,



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Date: October 16, 2006

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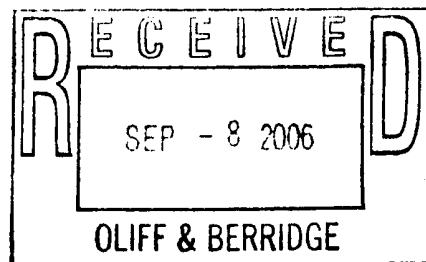


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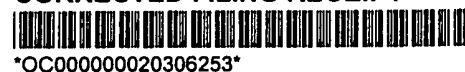
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APPL NO.	FILING OR 371 (c) DATE	ART UNIT	FIL FEE REC'D	ATTY. DOCKET NO	DRAWINGS	TOT CLMS	IND CLMS
10/539,569	08/18/2005	2812	2080	124305	18	21	8

25944
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CONFIRMATION NO. 4496
 CORRECTED FILING RECEIPT



OC000000020306253

Date Mailed: 09/05/2006

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Applicant(s)

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Assignment For Published Patent Application

(1) Hitachi Kokusai Electric Inc., Tokyo, JAPAN

(2) Adtec Plasma Technology Co., Ltd., Hiroshima, JAPAN

Power of Attorney: The patent practitioners associated with Customer Number 25944.

Domestic Priority data as claimed by applicant

This application is a 371 of PCT/JP03/16887 12/26/2003

Foreign Applications

JAPAN 2002-379963 12/27/2002

If Required, Foreign Filing License Granted: 05/16/2006

The country code and number of your priority application, to be used for filing abroad under the Paris Convention, is **US10/539,569**

Projected Publication Date: Not Applicable

Non-Publication Request: No

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(5) Tamiya Fujiwara, Iwate, JAPAN

Early Publication Request: No

Title

Plasma generator, ozone generator, substrate processing apparatus and manufacturing method of semiconductor device

Preliminary Class

438

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